IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Priority Application Serial No	
Priority Filing Date	June 22, 2000
Inventor	John T. Moore
Assignee	Micron Technology, Inc.
Priority Group Art Unit	
Priority Examiner	
Attorney's Docket No.	
Title: (As amended) Methods of Forming Dielect	
Semiconductor Substrates	

PRELIMINARY AMENDMENT

To:

MS Patent Application

Commissioner for Patents

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AMENDMENTS

Introductory Comments

Applicant amends the application and remarks as follows.